

# Eight Young Scientists to be Presented with Student Awards

Again this year, Student Awards will be presented to a group of graduate students who are conducting outstanding research in a topic to be addressed by one of the symposia at the Spring Meeting. The chairman of the MRS Awards Committee, Elton Kaufmann, announced that awards will be presented to eight students who are presenting papers in seven of the Spring Meeting symposia. A large number of applications were received for these awards, and the Awards Committee was faced with the difficult task of determining the recipients of a limited number of awards from a large group of highly qualified individuals. Kaufmann states, "The purpose of the Graduate Student Award Program is to recognize the contributions of graduate students to materials research, and to encourage the active participation of students in the meetings and other activities of MRS. The fact that a large number of applications have been received for these awards demonstrates that a growing number of highly qualified students are becoming aware of the programs and objectives of the Society. Student Awards will also be presented at the Fall Meeting and students are encouraged to submit applications now for the Fall Meeting awards."

The award recipients and the titles of their contributions to the Spring Meeting program are listed below.

**Stephanie M. Koch**

*Stanford University*

Field of Study: Materials Science, Symposium A: Heteroepitaxy on Silicon Technology, Paper: The Growth of GaAs on Si by Molecular Beam Epitaxy

**Leslie A. Kolodziejski**

*Purdue University*

Field of Study: Electrical Engineering, Symposium B: Compound Semiconductor Materials, Paper: MBE of II-VI Semiconductors

**Douglas A. Doughty**

*University of Wisconsin-Madison*

Field of Study: Physics, Symposium C: Plasma Processing, Paper: An Investigation of the Cathode Fall

**Jeffrey C. McCallum**

*University of Melbourne*

Field of Study: Applied Nuclear Physics, Symposium D: Materials Characterization, Paper: Channeling Contrast Microscopy: A Powerful Technique for Examining Semiconductor Structures

**Karen K. Gleason**

*University of California-Berkeley*

Field of Study: Chemical Engineering, Symposium E: Materials Issues in Amorphous Semiconductor Technology, Paper: Multiple Quantum NMR Study of Hydrogen Clustering in Amorphous Silicon

**Chris M. Gronet**

*Stanford University*

Field of Study: Semiconductor Processing, Symposium F: Materials Issues in Silicon Integrated Circuit Processing, Paper: Limited Reaction Processing; Heteroepitaxial Deposition

**Kenton D. Budd**

*University of Illinois-Urbana*

Field of Study: Ceramic Engineering, Symposium H: Better Ceramics Through Chemistry, Paper: Sol-Gel Processing of PbTiO<sub>3</sub> Thin Films

**Burtrand I. Lee**

*University of Florida-Gainesville*

Field of Study: Ceramic Science, Symposium H: Better Ceramics Through Chemistry, Paper: Silicon Carbide from Organosilanes and Applications in Silica Gel Glass Composites



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